

Cambridge University Press

978-1-107-40839-5 - Microelectromechanical Systems—Materials and Devices II: Materials

Research Society Symposium Proceedings: Volume 1139

Editors: Srikar Vengallatore, Jörg Bagdahn, Norman F. Sheppard and S. Mark Spearing

Frontmatter

[More information](#)

**Microelectromechanical
Systems—Materials and
Devices II**

Cambridge University Press

978-1-107-40839-5 - Microelectromechanical Systems—Materials and Devices II: Materials Research Society Symposium Proceedings: Volume 1139
Editors: Srikar Vengallatore, Jörg Bagdahn, Norman F. Sheppard and S. Mark Spearing
Frontmatter
[More information](#)

Cambridge University Press
978-1-107-40839-5 - Microelectromechanical Systems—Materials and Devices II: Materials Research Society Symposium Proceedings: Volume 1139
Editors: Srikar Vengallatore, Jörg Bagdahn, Norman F. Sheppard and S. Mark Spearing
Frontmatter
[More information](#)

**MATERIALS RESEARCH SOCIETY
SYMPOSIUM PROCEEDINGS VOLUME 1139**

**Microelectromechanical
Systems—Materials
and Devices II**

Symposium held December 1–2, 2008, Boston, Massachusetts, U.S.A.

EDITORS:

Srikar Vengallatore

McGill University
Montreal, Canada H3A 2K6

Jörg Bagdahn

Fraunhofer Center for Silicon Photovoltaics
Halle (Saale), Germany

Norman F. Sheppard Jr.

MicroCHIPS, Inc.
Bedford, Massachusetts, U.S.A.

S. Mark Spearing

University of Southampton
Southampton, United Kingdom



Materials Research Society
Warrendale, Pennsylvania

Cambridge University Press

978-1-107-40839-5 - Microelectromechanical Systems—Materials and Devices II: Materials

Research Society Symposium Proceedings: Volume 1139

Editors: Srikanth Vengallatore, Jörg Bagdahn, Norman F. Sheppard and S. Mark Spearing

Frontmatter

[More information](#)

CAMBRIDGE UNIVERSITY PRESS

Cambridge, New York, Melbourne, Madrid, Cape Town,
Singapore, São Paulo, Delhi, Mexico City

Cambridge University Press

32 Avenue of the Americas, New York NY 10013-2473, USA

Published in the United States of America by Cambridge University Press, New York

www.cambridge.org

Information on this title: www.cambridge.org/9781107408395

Materials Research Society

506 Keystone Drive, Warrendale, PA 15086

<http://www.mrs.org>

© Materials Research Society 2009

This publication is in copyright. Subject to statutory exception
and to the provisions of relevant collective licensing agreements,
no reproduction of any part may take place without the written
permission of Cambridge University Press.

This publication has been registered with Copyright Clearance Center, Inc.
For further information please contact the Copyright Clearance Center,

Salem, Massachusetts.

First published 2009

First paperback edition 2012

Single article reprints from this publication are available through
University Microfilms Inc., 300 North Zeeb Road, Ann Arbor, MI 48106

CODEN: MRSPDH

ISBN 978-1-107-40839-5 Paperback

Cambridge University Press has no responsibility for the persistence or
accuracy of URLs for external or third-party internet websites referred to in
this publication, and does not guarantee that any content on such websites is,
or will remain, accurate or appropriate.

Cambridge University Press

978-1-107-40839-5 - Microelectromechanical Systems—Materials and Devices II: Materials

Research Society Symposium Proceedings: Volume 1139

Editors: Srikar Vengallatore, Jörg Bagdahn, Norman F. Sheppard and S. Mark Spearing

Frontmatter

[More information](#)

CONTENTS

Preface	xi
----------------------	----

Materials Research Society Symposium Proceedings.....	xii
--	-----

MATERIALS AND PROCESSES FOR MEMS

* Commercial MEMS Case Studies: The Impact of Materials, Processes and Designs	3
---	---

Jack Martin

A Novel Gap Narrowing Process for Creating High Aspect Ratio Transduction Gaps for MEM HF Resonators	13
---	----

Steve Stoffels, George Bryce, Rita Van Hoof,
Bert Du Bois, Robert Mertens, Robert Puers,
Harrie A. Tilmans, and Ann Witvrouw

Dicing of Fragile MEMS Structures	19
--	----

Peter Lange, Norman Marenco, Sven Gruenzig,
Stephan Warnat, and Thilo Semperowitsch

MICRODEVICES AND MICRO/NANOFUIDICS

* BioMEMS Technologies for Regenerative Medicine.....	27
--	----

Jeffrey T. Borenstein

POSTER SESSION

Design and Fabrication of MEMS Piezoelectric Rotational Actuators	41
--	----

Danny Gee, Wayne Churaman, Luke Curran,
and Eugene Zakar

Measurement and Analysis of Structural Damping in Silicon Carbide Microresonators.....	47
---	----

Sairam Prabhakar, Frederic Nabki, Mourad El-Gamal,
and Srikar Vengallatore

*Invited Paper

Cambridge University Press

978-1-107-40839-5 - Microelectromechanical Systems—Materials and Devices II: Materials

Research Society Symposium Proceedings: Volume 1139

Editors: Srikar Vengallatore, Jörg Bagdahn, Norman F. Sheppard and S. Mark Spearing

Frontmatter

[More information](#)

Fabrication and Hot Switching Behavior of Electroplated Gallium Spheres for MEMS	53
Yoonkap Kim and David Bahr	
Fast and Controlled Integration of Carbon Nanotubes Into Microstructures	59
Wenjun Xu, Chang-Hyeon Ji, Richard Shafer, and Mark Allen	
Through Silicon Vias in Micro-Electromechanical Systems	65
Stephan Warnat, Ramona Ecke, Norman Marenco, Sven Gruenzig, Wolfgang Reinert, and Peter Lange	
Effects of Aspect Ratio of Micro-Sized Photoresist Patterns on Bond Strength Between a Si Substrate with AFM Fracture Observation.....	71
Chiemi Ishiyama, Akinobu Shibata, Masato Sone, and Yakichi Higo	
Resonance Fatigue Testing of Cantilever Specimens Prepared From Thin Films	77
Kwang sik Kwak, Masaaki Otsu, and Kazuki Takashima	
Bending of Pd-Based Thin Film Metallic Glasses by Laser Forming Process.....	83
Yuki Ide, Masaaki Otsu, Junpei Sakurai, Seiichi Hata, and Kazuki Takashima	
Droplet Formation at Microfluidic T-Junctions	89
Yu Xiang and David A. LaVan	
Controlling the Wrinkling of the Bilayer Thin Films Electrothermally.....	97
Shravan Chintapatla, John F. Muth, and Leda M. Lunardi	

Cambridge University Press

978-1-107-40839-5 - Microelectromechanical Systems—Materials and Devices II: Materials

Research Society Symposium Proceedings: Volume 1139

Editors: Srikar Vengallatore, Jörg Bagdahn, Norman F. Sheppard and S. Mark Spearing

Frontmatter

[More information](#)

Thermal Bubble Nucleation in Nanochannels: Simulations and Strategies for Nanobubble Nucleation and Sensing	103
Manoj Sridhar, Dongyan Xu, Anthony B. Hmelo, Deyu Li, and Leonard C. Feldman	
Rapid Cell Manipulation by Rotating Nanowires.....	109
Hansong Zeng, Joshua Ebel, and Yi Zhao	
Novel Technique to Determine Elastic Constants of Thin Films	115
Jozef Keckes, Klaus Martinschitz, Christian Mitterer, and Rostislav Daniel	
Surface Treated PDMS by UV-Vis Light Applied to Microfluidic Device.....	121
Seisuke Kano, Sohei Matsumoto, and Naoki Ichikawa	
Metal Wafer Bonding for MEMS Applications	127
Viorel Dragoi, Gerald Mittendorfer, Franz Murauer, Erkan Cakmak, and Eric Pabo	
Effect of Process Variables on Glass Frit Wafer Bonding in MEMS Wafer Level Packaging	133
Sid Sridharan, Jim Henry, John Maloney, Bob Gardner, Keith Mason, Viorel Dragoi, Eric Pabo, Erkan Cakmak, and Jurgen Burggraf	
Charging Processes in Silicon Nitride Films for RF- MEMS Capacitive Switches: The Effect of Deposition Method and Film Thickness.....	141
Usama Zaghloul, George Papaioannou, Robert Plana, Fabio Coccetti, Patrick Pons, and Aissa Belarni	
A Perturbation-Based Method for Extracting Elastic Properties During Spherical Indentation of an Elastic Film/Substrate Bilayer	147
Jae Hun Kim, Andrew Gouldstone, and Chad S. Korach	

Microfabrication of Si/SiO₂—Spherical Shells as a Path to Sub-mm³ Autonomous Robotic Systems.....	153
Vladimir Vasilyev, James R. Reid, and Richard T. Webster	
Transport of Charged Species Across Solid-State Nanopores.....	159
Daisy Fung, Eyup Akdemir, Michael Vitarelli, Eugene Sosnov, and Shaurya Prakash	
Fabrication and Piezoelectric Characterization of AlN Mesa Structures	163
R. Farrell, A. Kabulski, V.R. Pagán, S. Yeldandi, X.A. Cao, P. Famouri, J.P. Hensel, and D. Korakakis	
Investigating the Stress and Crystal Quality of AlN Air-Bridges Through Micro-Raman Scattering.....	169
Sridhar Kuchibhatla, L.E. Rodak, and D. Korakakis	
Aluminum Nitride Thin Film Based Surface Acoustic Wave Sensors	175
A. Kabulski, V.R. Pagán, D. Cortes, R. Burda, O.M. Mukdadi, and D. Korakakis	
Active Field Effect Capacitive Sensors for High-Throughput, Label-Free Nucleic Acid Analysis.....	181
Manu Sebastian Mannoor, Teena James, Dentcho V. Ivanov, Bill Braunlin, and Les Beadling	
Growth of Epitaxial Potassium Niobate Film on (100)SrRuO₃/(100)SrTiO₃ by Hydrothermal Method and Their Electromechanical Properties.....	187
Mutsuo Ishikawa, Shintaro Yasui, Satoru Utsugi, Takashi Fujisawa, Tomoaki Yamada, Takeshi Morita, Minoru Kurosawa, and Hiroshi Funakubo	
Bio-Compatible Micro-Sensor for Blood Pressure Measurement Using SiC Technology	193
Gary L. Harris, Nupur Basak, Ken Wise, and James Griffin	

Cambridge University Press

978-1-107-40839-5 - Microelectromechanical Systems—Materials and Devices II: Materials

Research Society Symposium Proceedings: Volume 1139

Editors: Srikan Vengallatore, Jörg Bagdahn, Norman F. Sheppard and S. Mark Spearing

Frontmatter

[More information](#)***MICRO/NANOMECHANICS***

* CMOS-Integrated Stress Sensor Systems for Mechanical Sensing and Packaging Reliability Testing	201
Oliver Paul, Pascal Gieschke, and Benjamin Lemke	
Evaluation of the Mechanical Properties of Aluminum Thin Films as a Function of Strain Rate Using the Wafer-Scale Microtensile Technique	211
Joao Gaspar, Marek E. Schmidt, Jochen Held, and Oliver Paul	
Micro Tensile Tests on Aluminium Thin Films: Tensile Device and In Situ Observations	217
Michel T. Ignat, Sabine Lay, Francine Roussel d'Herbey, Cedric Seguinéau, Christophe Malhaire, Jean Michel Desmarres, Xavier Lafontan, and Sebastiano Brida	
Strength and Fatigue Life of Nanocrystalline Titanium/Platinum Multilayer Membranes for Implantable MEMS Reservoir Array Devices	225
Karl Yoder, John Maloney, and Jonathan Coppeta	

MEMS RELIABILITY AND TRIBOLOGY

Investigation of Gold Sputter Coated Vertically Aligned Multi-Walled Carbon Nanotubes for RF MEMS Contact Surfaces	233
Esa Yunus, S. Mark Spearing, and John McBride	
An Improved Nanotribological System for Hard Disk Drives	239
Xuan Li and James Economy	

Author Index	245
Subject Index.....	247

*Invited Paper

Cambridge University Press

978-1-107-40839-5 - Microelectromechanical Systems—Materials and Devices II: Materials Research Society Symposium Proceedings: Volume 1139
Editors: Srikar Vengallatore, Jörg Bagdahn, Norman F. Sheppard and S. Mark Spearing
Frontmatter

[More information](#)

Cambridge University Press

978-1-107-40839-5 - Microelectromechanical Systems—Materials and Devices II: Materials

Research Society Symposium Proceedings: Volume 1139

Editors: Srikar Vengallatore, Jörg Bagdahn, Norman F. Sheppard and S. Mark Spearing

Frontmatter

[More information](#)

PREFACE

Over the past fifteen years, Microelectromechanical Systems (MEMS) have transitioned from occupying a technology niche to having major industrial significance. The worldwide market for MEMS is now approximately \$10 billion, and the total value of systems enabled by MEMS is several orders of magnitude higher than this figure. Initially, commercially successful MEMS utilized pre-existing materials and processes derived from conventional silicon-based semiconductor microelectronics. As the market has grown the material and process sets have broadened and departed from their semiconductor roots. The opportunities created by this broadening have generated a vibrant research community working on new materials and processes. In addition, during this period, MEMS and microfabrication have become important tools for the development and characterization of materials in general. Beginning in 1998, a series of Materials Research Society symposia has documented these trends. This proceedings volume reports on research presented at the latest of these symposia, Symposium GG, "Microelectromechanical Systems—Materials and Devices II," which was held December 1–2 at the 2008 MRS Fall Meeting in Boston, Massachusetts.

The topics covered by the symposium and in these proceedings provide an accurate reflection of the breadth of topics currently under investigation in this field. Many novel materials and accompanying processes are discussed, as well as detailed analyses of more conventional materials and processes. A consistent theme in previous symposia has been the need to conduct accurate material property assessment at the relevant length scales and the need for suitable metrology tools to support the introduction of new materials. These topics are well represented in the present proceedings. We also note the increasing trend towards the inclusion of papers in the proceedings that demonstrate the close coupling between the materials, processes and the MEMS they have been developed for. The growth in the number of papers with this character is a positive indication of the highly interdisciplinary nature of the field and also the extent to which researchers in the community have embraced the need to address system design issues as well as fundamental material science.

There is every indication that the continued growth of MEMS as an important area of technology will continue to provide a strong motivation for the accompanying development of materials and processes. We fully expect that the MRS symposium will also continue to provide a record of these developments.

Srikanth Vengallatore
Jörg Bagdahn
Norm Sheppard
S. Mark Spearing

March 2009

Cambridge University Press

978-1-107-40839-5 - Microelectromechanical Systems—Materials and Devices II: Materials

Research Society Symposium Proceedings: Volume 1139

Editors: Srikar Vengallatore, Jörg Bagdahn, Norman F. Sheppard and S. Mark Spearing

Frontmatter

[More information](#)

MATERIALS RESEARCH SOCIETY SYMPOSIUM PROCEEDINGS

- Volume 1108 — Performance and Reliability of Semiconductor Devices, M. Mastro, J. LaRoche, F. Ren, J.-I. Chyi, J. Kim, 2009, ISBN 978-1-60511-080-6
- Volume 1109E — Transparent Conductors and Semiconductors for Optoelectronics, J.D. Perkins, T.O. Mason, J.F. Wager, Y. Shigesato, 2009, ISBN 978-1-60511-081-3
- Volume 1110E — Theory and Applications of Ferroelectric and Multiferroic Materials, M. Dawber, 2009, ISBN 978-1-60511-082-0
- Volume 1111 — Rare-Earth Doping of Advanced Materials for Photonic Applications, V. Dierolf, Y. Fujiwara, U. Hommerich, P. Ruterana, J. Zavada, 2009, ISBN 978-1-60511-083-7
- Volume 1112 — Materials and Technologies for 3-D Integration, F. Roozeboom, C. Bower, P. Garrou, M. Koyanagi, P. Ramm, 2009, ISBN 978-1-60511-084-4
- Volume 1113E — Low-Cost Solution-Based Deposition of Inorganic Films for Electronic/Photonic Devices, D.B. Mitzi, D. Ginley, B. Smarsly, D.V. Talapin, 2009, ISBN 978-1-60511-085-1
- Volume 1114E — Organic and Hybrid Materials for Large-Area Functional Systems, A. Salleo, A.C. Arias, D.M. DeLongchamp, C.R. Kagan, 2009, ISBN 978-1-60511-086-8
- Volume 1115 — Physics and Technology of Organic Semiconductor Devices, M. Baldo, A. Kahn, P.W.M. Blom, P. Peumans, 2009, ISBN 978-1-60511-087-5
- Volume 1116E — Reliability and Properties of Electronic Devices on Flexible Substrates, J.R. Greer, J. Vlassak, J. Daniel, T. Tsui, 2009, ISBN 978-1-60511-088-2
- Volume 1117E — Materials Science for Quantum Information Processing Technologies, M. Fanciulli, J. Martinis, M. Eriksson, 2009, ISBN 978-1-60511-089-9
- Volume 1118E — Magnetic Nanostructures by Design, J. Shen, Z. Bandic, S. Sun, J. Shi, 2009, ISBN 978-1-60511-090-5
- Volume 1119E — New Materials with High Spin Polarization and Their Applications, C. Felser, A. Gupta, B. Hillebrands, S. Wurmehl, 2009, ISBN 978-1-60511-091-2
- Volume 1120E — Energy Harvesting—Molecules and Materials, D.L. Andrews, K.P. Ghiggino, T. Goodson III, A.J. Nozik, 2009, ISBN 978-1-60511-092-9
- Volume 1121E — Next-Generation and Nano-Architecture Photovoltaics, V.G. Stoleru, A.G. Norman, N.J. Ekins-Daukes, 2009, ISBN 978-1-60511-093-6
- Volume 1122E — Structure/Property Relationships in Fluorite-Derivative Compounds, K.E. Sickafus, A. Navrotsky S.R. Phillipot, 2009, ISBN 978-1-60511-094-3
- Volume 1123 — Photovoltaic Materials and Manufacturing Issues, B. Sopori, J. Yang, T. Surek, B. Dimmler, 2009, ISBN 978-1-60511-095-0
- Volume 1124 — Scientific Basis for Nuclear Waste Management XXXII, R.B. Rebak, N.C. Hyatt, D.A. Pickett, 2009, ISBN 978-1-60511-096-7
- Volume 1125 — Materials for Future Fusion and Fission Technologies, C.C. Fu, A. Kimura, M. Samaras, M. Serrano de Caro, R.E. Stoller, 2009, ISBN 978-1-60511-097-4
- Volume 1126 — Solid-State Ionics—2008, E. Traversa, T. Armstrong, K. Eguchi, M.R. Palacin, 2009, ISBN 978-1-60511-098-1
- Volume 1127E — Mobile Energy, M.C. Smart, M. Nookala, G. Amaralunga, A. Nathan, 2009, ISBN 978-1-60511-099-8
- Volume 1128 — Advanced Intermetallic-Based Alloys for Extreme Environment and Energy Applications, M. Palm, Y-H. He, B.P. Bewlay, M. Takeyama, J.M.K. Wiezorek, 2009, ISBN 978-1-60511-100-1
- Volume 1129 — Materials and Devices for Smart Systems III, J. Su, L-P. Wang, Y. Furuya, S. Trolier-McKinstry, J. Leng, 2009, ISBN 978-1-60511-101-8
- Volume 1130E — Computational Materials Design via Multiscale Modeling, H.E. Fang, Y. Qi, N. Reynolds, Z-K. Liu, 2009, ISBN 978-1-60511-102-5
- Volume 1131E — Biomaterial Interfaces—From Experiment to Theory, J.H. Harding, J.A. Elliott, J.S. Evans, 2009, ISBN 978-1-60511-103-2

Cambridge University Press

978-1-107-40839-5 - Microelectromechanical Systems—Materials and Devices II: Materials

Research Society Symposium Proceedings: Volume 1139

Editors: Srikar Vengallatore, Jörg Bagdahn, Norman F. Sheppard and S. Mark Spearing

Frontmatter

[More information](#)

MATERIALS RESEARCH SOCIETY SYMPOSIUM PROCEEDINGS

- Volume 1132E —Mechanics of Biological and Biomedical Materials, R. Narayan, K. Katti, C. Hellmich, U.G.K. Wegst, 2009, ISBN 978-1-60511-104-9
- Volume 1133E —Materials for Optical Sensors in Biomedical Applications, D. Nolte, P. Kiesel, X. Fan, G. Hong, 2009, ISBN 978-1-60511-105-6
- Volume 1134 — Polymer-Based Smart Materials—Processes, Properties and Application, Z. Cheng, Q. Zhang, S. Bauer, D.A. Wroblewski, 2009, ISBN 978-1-60511-106-3
- Volume 1135E —Design, Fabrication, and Self Assembly of "Patchy" and Anisometric Particles, E. Luijten, S.C. Glotzer, F. Sciortino, 2009, ISBN 978-1-60511-107-0
- Volume 1136E —Materials in Tissue Engineering, T. Webster, 2009, ISBN 978-1-60511-108-7
- Volume 1137E —Nano- and Microscale Materials—Mechanical Properties and Behavior under Extreme Environments, A. Misra, T.J. Balk, H. Huang, M.J. Caturla, C. Eberl, 2009, ISBN 978-1-60511-109-4
- Volume 1138E —Nanofunctional Materials, Structures and Devices for Biomedical Applications, L. Nagahara, T. Thundat, S. Bhatia, A. Boisen, K. Kataoka, 2009, ISBN 978-1-60511-110-0
- Volume 1139 — Microelectromechanical Systems—Materials and Devices II, S.M. Spearing, S. Vengallatore, J. Bagdahn, N. Sheppard, 2009, ISBN 978-1-60511-111-7
- Volume 1140E —Advances in Material Design for Regenerative Medicine, Drug Delivery and Targeting/Imaging, V.P. Shastri, A. Lendlein, L.S. Liu, S. Mitragotri, A. Mikos, 2009, ISBN 978-1-60511-112-4
- Volume 1141E —Bio-Inspired Transduction, Fundamentals and Applications, T. Vo-Dinh, C. Liu, A. Zribi, Y. Zhao, 2009, ISBN 978-1-60511-113-1
- Volume 1142 — Nanotubes, Nanowires, Nanobelts and Nanocoils—Promise, Expectations and Status, P. Bandaru, S. Grego, I. Kinloch, 2009, ISBN 978-1-60511-114-8
- Volume 1143E —Transport Properties in Polymer Nanocomposites, J. Grunlan, M. Ellsworth, S. Nazarenko, J.-F. Feller, B. Pivovar, 2009, ISBN 978-1-60511-115-5
- Volume 1144 — Nanowires—Synthesis, Properties, Assembly and Applications, Y. Cui, E.P.A.M. Bakkers, L. Lauhon, A. Talin, 2009, ISBN 978-1-60511-116-2
- Volume 1145E —Applications of Group IV Semiconductor Nanostructures, T. van Buuren, L. Tsybeskov, S. Fukatsu, L. Dal Negro, F. Gourbilleau, 2009, ISBN 978-1-60511-117-9
- Volume 1146E —*In Situ* Studies across Spatial and Temporal Scales for Nanoscience and Technology, S. Kodambaka, G. Rijnders, A. Petford-Long, A. Minor, S. Helveg, A. Ziegler, 2009, ISBN 978-1-60511-118-6
- Volume 1147E —Grazing-Incidence Small-Angle X-Ray Scattering, B. Ocko, J. Wang, K. Ludwig, T.P. Russell, 2009, ISBN 978-1-60511-119-3
- Volume 1148E —Solid-State Chemistry of Inorganic Materials VII, P.M. Woodward, J.F. Mitchell, S.L. Brock, J.S.O. Evans, 2009, ISBN 978-1-60511-120-9
- Volume 1149E —Synthesis and Processing of Organic and Polymeric Functional Materials for a Sustainable Energy Economy, J. Li, C-C. Wu, S.Y. Park, F.B. McCormick, 2009, ISBN 978-1-60511-121-6
- Volume 1150E —Artificially Induced Grain Alignment in Thin Films, V. Matias, R. Hammond, S-H. Moon, R. Hühne, 2009, ISBN 978-1-60511-122-3
- Volume 1151E —Selecting and Qualifying New Materials for Use in Regulated Industries, R. Rogge, J. Theaker, C. Hubbard, R. Schneider, 2009, ISBN 978-1-60511-123-0
- Volume 1152E —Local Structure and Dynamics in Amorphous Systems, Jeff Th.M. de Hosson, A.L. Greer, C.A. Volkert, K.F. Kelton, 2009, ISBN 978-1-60511-124-7

Prior Materials Research Society Symposium Proceedings available by contacting Materials Research Society